

DOCKET NO.: 288992US0PCT



IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

GROUP: 2812

Yasuo MATSUKI, et al.

SERIAL NO: 10/575,478

ATTENTION:  
FILING RECEIPT CORRECTIONS

FILED: April 12, 2006

FOR: COMPOSITION FOR FORMING SILICON-COBALT FILM, SILICON-COBALT FILM AND METHOD FOR FORMING SAME

**REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT**

Office of Initial Patent Examination  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

The Patent Office is requested to provide a corrected Official Filing Receipt for the following.

PLEASE NOTE THAT THE FOREIGN APPLICATION DATA IS INCORRECT. IT SHOULD READ AS FOLLOWS:

JAPAN 2003-356158 10/16/2003

PLEASE NOTE THAT THE TITLE IS INCORRECT. IT SHOULD READ AS FOLLOWS:

COMPOSITION FOR FORMING SILICON-COBALT FILM,  
SILICON-COBALT FILM AND METHOD FOR FORMING SAME

No fees are required. If you have any questions, please do not hesitate to contact us.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,  
MAIER & NEUSTADT, P.C.  
Norman F. Oblon

A handwritten signature in black ink, appearing to read "Paul J. Killos", is written over a horizontal line.

Paul J. Killos  
Registration No. 58,014

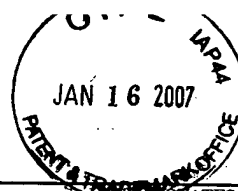
Customer Number

**22850**

Tel. (703) 413-3000  
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(OSMMN 03/06)  
Docket # 288992US  
Serial # 10/575,478



## UNITED STATES PATENT AND TRADEMARK OFFICE



UNITED STATES DEPARTMENT OF COMMERCE  
United States Patent and Trademark Office  
Address: COMMISSIONER FOR PATENTS  
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Alexandria, Virginia 22313-1450  
www.uspto.gov

APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/575,478	04/12/2006	2812	900	288992US0PCT	1	5	1

CONFIRMATION NO. 3424

22850  
OBLON, SPIVAK, MCCLELLAND, MAIER & NEUSTADT, P.C.  
1940 DUKE STREET  
ALEXANDRIA, VA 22314

## FILING RECEIPT



\*OC000000021758143\*

Date Mailed: 12/29/2006

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

Yasuo Matsuki, Tokyo, JAPAN;  
Daohai Wang, Tokyo, JAPAN;  
Tatsuya Sakai, Tokyo, JAPAN;  
Haruo Iwasawa, Tokyo, JAPAN;

## Assignment For Published Patent Application

JSR Corporation, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number **22850**.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/15101 10/06/2004

## Foreign Applications

JAPAN 2003-~~361~~158 10/16/2003

356

If Required, Foreign Filing License Granted: 12/27/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/575,478**

Projected Publication Date: 04/05/2007

RECEIVED: 1/3/07  
OBLON, SPIVAK, MCCLELLAND  
MAIER & NEUSTADT, P.C.  
DOCKETING DEPT  
Initials/Date Docketed: AP 1/4/07  
Type of Resp(s): \_\_\_\_\_  
Due Date(s): \_\_\_\_\_

**Non-Publication Request:** No

**Early Publication Request:** No

**Title**

Composition for forming silicon-cobalt film, silicon-cobalt film and method <sup>For</sup> forming same

**Preliminary Class**

438

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Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process **simplifies** the filing of patent applications on the same invention in member countries, but **does not result** in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

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For information on preventing theft of your intellectual property (patents, trademarks and copyrights), you may wish to consult the U.S. Government website, <http://www.stopfakes.gov>. Part of a Department of Commerce initiative, this website includes self-help "toolkits" giving innovators guidance on how to protect intellectual property in specific countries such as China, Korea and Mexico. For questions regarding patent enforcement issues, applicants may call the U.S. Government hotline at 1-866-999-HALT (1-866-999-4158).

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DOCKET NO.: 288992US0PCT/sma

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

IN RE APPLICATION OF:

Yasuo MATSUKI, et al.

GROUP: 2812

SERIAL NO: 10/575,478

FILED: April 12, 2006

EXAMINER:

FOR: COMPOSITION FOR FORMING SILICON-COBALT FILM, SILICON-COBALT FILM AND METHOD FOR FORMING SAME

**SUBMISSION OF SUPPLEMENTAL APPLICATION DATA SHEET**

Office of Initial Patent Examination  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant(s) submit herewith a Supplemental Application Data Sheet for the above-identified application for the purpose of adding the Assignment information.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,  
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Norman F. Oblon

Paul J. Killos  
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Customer Number

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(OSMMN 06/04)



## SUPPLEMENTAL APPLICATION DATA SHEET

### APPLICATION INFORMATION

Application Number:: 10/575,478  
Application Date:: 04/12/06  
Application Type:: REGULAR  
Subject Matter:: UTILITY  
CD-ROM or CD-R?: NONE  
Title:: COMPOSITION FOR FORMING  
SILICON-COBALT FILM, SILICON-  
COBALT FILM AND METHOD FOR  
FORMING SAME  
  
Attorney Docket Number:: 288992US0PCT  
Total Drawing Sheets:: 1

### INVENTOR INFORMATION

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Postal or Zip Code of Mailing Address:: 104-0045

#### CORRESPONDENCE INFORMATION

Correspondence Customer Number:: 22850

#### REPRESENTATIVE INFORMATION

Representative Customer Number:: 22850

#### DOMESTIC PRIORITY INFORMATION

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This Application	National Stage of	PCT/JP04/15101	10/06/04

#### FOREIGN PRIORITY INFORMATION

Application Number:	Country::	Filing Date::	Priority Claimed::
2003-356158	Japan	10/16/03	YES

#### ASSIGNMENT INFORMATION



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